



Form 1449 (Modified) Information Disclosure Statement By Applicant (Use Several Sheets if Necessary)	Atty Docket No. INT1P206C1 Application No.: 10/800,393 Inventor NAIMARK, et al Group 2171 2165 Filing Date March 12, 2004
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U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
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Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation	
	L						Yes	No

Other Documents

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MA	M	"About Upoc", http://www.upoc.com/about.jsp ; February 7, 2001
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	O	Guernsey, Lisa, "Mining the 'Deep Web' with Specialized Drills", January 25, 2001, The New York Times.
	P	http://my.zdnet.com/myzdnet/alerthelp , September 25, 2000
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	S	Schwab, Pohl and Koychev, "Learning to Recommend from Positive Evidence", GMD-FIT, MMK, D-53754 Sankt Augustin, Germany.
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Examiner		Date Considered 6/24/06

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.